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CENTRAL FAX CENTER****FEB 15 2007****CLAIMS**

1. (Currently Amended) A process for producing a non-aqueous sol-gel spin-on glass material comprising a hybrid glass/polymer material, by reacting an alkyl ~~or dialkyl~~ substituted trialkoxysilane or dialkyl substituted dialkoxysilane with a silane diol, wherein said alkyl group has from 1 to 8 carbon atoms, wherein the reaction of the alkyl substituted trialkoxysilane or dialkyl substituted dialkoxysilane silane with the silane diol is carried out in a non-aqueous medium in the presence of a catalyst, wherein the catalyst is selected from: a) a tin catalyst or b) a dibutyltin diluarate, titanium isopropoxide, acetic acid or trifluoroacetic acid catalyst.
2. (Original) The process of claim 1, wherein the silane diol is a diphenylsilanediol, a 1,3-Bis (3-hydroxypropyl) tetramethoxysilane, a 1,3-Bis (4-hydroxybutyl) tetramethylsilane, a fluorinated silane diol, or a mixture of one or more of these silane diols.
3. (Original) The process of claim 1, wherein the alkyl group is replaced with a methacryloxypropyl, acryloxypropyl, or epoxy moiety.
4. (Canceled)
5. (Original) The process of claim 1, wherein the trialkoxysilane or dialkoxysilane has 1 to 3 C₁ to C₈ alkyl, methacryloxypropyl and/or alkoxy groups on the same molecule.
6. (Canceled)
7. (Original) The process of claim 1, further comprising adding a phosphor dopant.
8. (Currently Amended) The process of claim 7, wherein the ~~copolymer comprises acrylic acid~~ phosphor dopant comprises YAG base phosphor or moisture sensitive

phosphor nano-particles or an organic material selected from organic dyes or metal complexes.

9. (Original) The process of claim 1, further comprising adding a UV light blocking material and/or an oxygen scavenger.

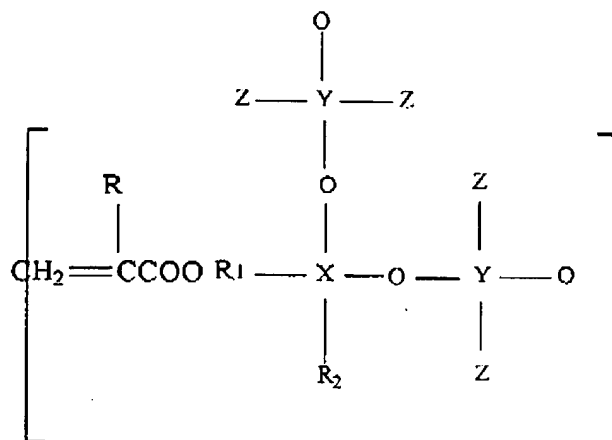
10. (Original) The process of claim 1, further comprising adding a light-scattering material.

11. (Original) The process of claim 1, further comprising adding a coupling agent.

12. (Original) The process of claim 11, wherein the coupling agent is a dibutoxyaluminoxetriethoxysilane, a mixture of zirconium isopropoxide and methacrylic acid, or another transition metal propoxide.

13-17 (Canceled)

18. (Currently Amended) A non-aqueous sol-gel spin-on glass material comprising a hybrid glass/polymer material containing a phosphor dopant, which comprises YAG base phosphor or moisture sensitive phosphor nano-particles or an organic material selected from organic dyes or metal complexes, said sol-gel spin-on-glass material selected from the group having the following formulas:

Formula I

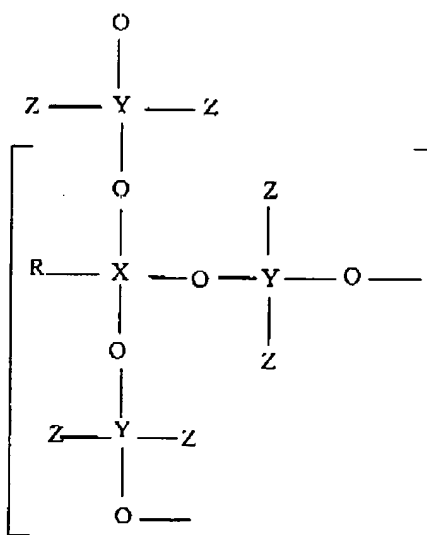
Where R = Hydrogen, C₁-C₈ Alkyl, Halogenated C₁-C₈ Alkyl or Glycidylalkoxyalkyl

R₁ = Ethyl, Propyl, another C₁-C₈ Alkyl, Halogenated C₁-C₈ Alkyl, Phenyl, or Halogenated Phenyl

R₂ = Methyl, Ethyl or another C₁-C₈ Alkyl, Methyl, Ethyl

X, Y = Si, Ge, Ti or Sn

Z = Alkyl, Substituted Alkyl, Phenyl, Substituted Phenyl

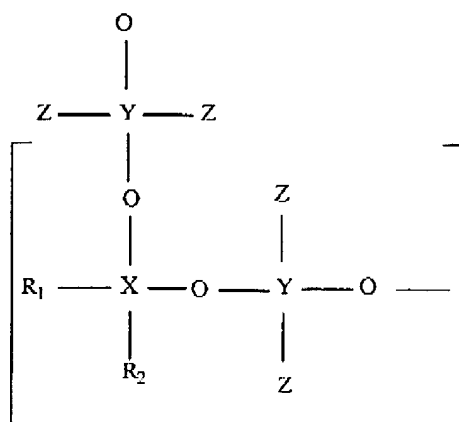
Formula II

Where R = Alkyl (C₁-C₈), Phenyl, Substituted Phenyl, Methacryloxyalkyl, Acryloxyalkyl or Glycidylalkoxyalkyl

R₁ = Phenyl or Substituted Phenyl, Ethyl, Propyl or another C₁ to C₈ Alkyl, or Trifluoroalkyl

X, Y = Si, Ti, Ge, or Sn

Z = Alkyl, Substituted Alkyl, Phenyl, Substituted Phenyl

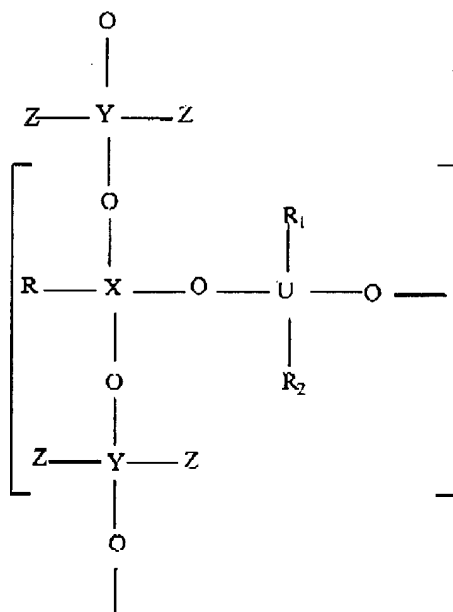
Formula III

Where R_1 = Phenyl or Substituted Phenyl, Ethyl, Propyl or another C_1 to C_8 Alkyl, or Trifluoroalkyl or Trifluoropropyl

R_2 = Methyl, Ethyl or another C_1 to C_8 Alkyl

X, Y = Si, Ge, Ti, or Sn

Z = Alkyl, Substituted Alkyl, Phenyl, Substituted Phenyl

Formula IV

Where R = Alkyl (C_1 to C_8), Phenyl, Substituted Phenyl, Methacryloxyalkyl, Acryloxyalkyl or Glycidyoxyalkyl

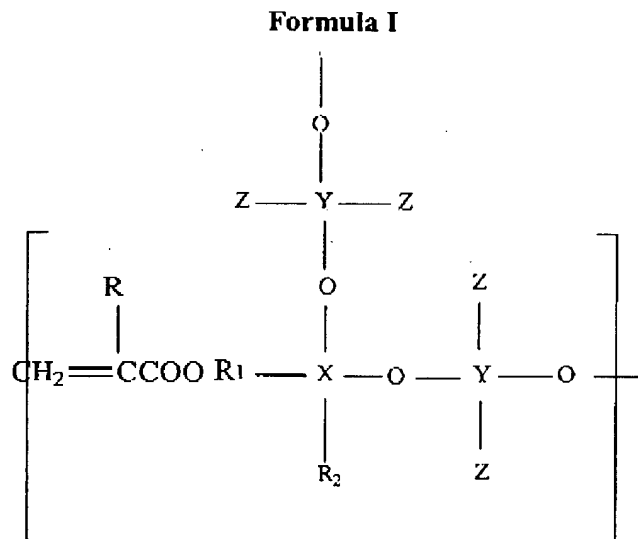
R_1 = Phenyl or Substituted Phenyl, Ethyl, Propyl or another C_1 to C_8 Alkyl, Phenyl or Trifluoroalkyl

R_2 = Alkyl, Methyl, Ethyl or another C_1 to C_8 Alkyl or Phenyl

$\text{X}, \text{U}, \text{Y}$ = Si, Ge, Ti, or Sn

Z = Alkyl, Substituted Alkyl, Phenyl, Substituted Phenyl

19. (Currently Amended) The non-aqueous sol-gel spin-on glass material of claim 18, having the following formula:



Where R = Hydrogen, C₁-C₈ Alkyl, Halogenated C₁-C₈ Alkyl or Glycidylalkyl

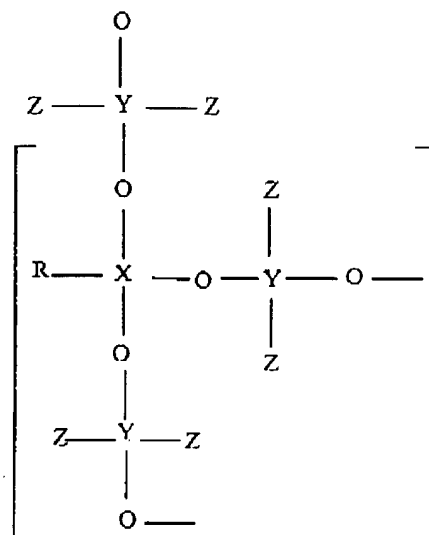
R₁ = Ethyl, Propyl, another C₁-C₈ Alkyl, Halogenated C₁-C₈ Alkyl, Phenyl or Halogenated Phenyl

R₂ = Methyl, Ethyl or another C₁-C₈ Alkyl

X, Y = Si, Ge, Ti or Sn

Z = Alkyl, Substituted Alkyl, Phenyl, Substituted Phenyl

20. (Currently Amended) The non-aqueous sol-gel spin-on glass material of claim 18, having the following formula:

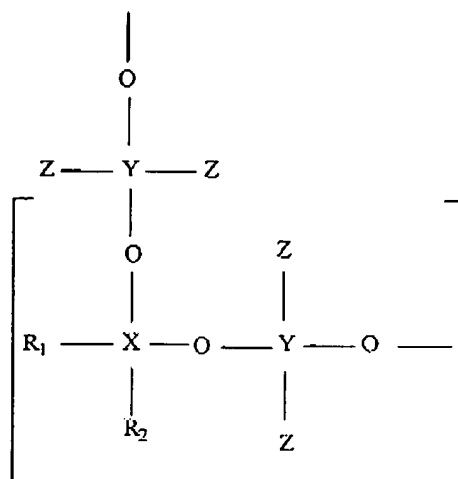
Formula II

Where R = Alkyl (C₁-C₈), Phenyl, Substituted Phenyl

X, Y = Si, Ti, Ge or Sn

Z = Alkyl, Substituted Alkyl, Phenyl, Substituted Phenyl

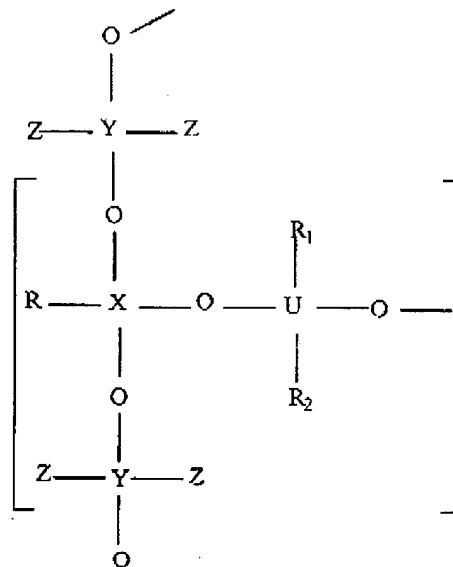
21. (Currently Amended) The non-aqueous sol-gel spin-on glass material of claim 18, having the following formula:

Formula III

Where R_1 = Phenyl, Ethyl, Propyl, Trifluoropropyl
 R_2 = Methyl, Ethyl
 X, Y = Si, Ge, Ti or Sn
 Z = ~~Alkyl, Substituted Alkyl, Phenyl, Substituted Phenyl~~

22. (Currently Amended) The non-aqueous sol-gel spin-on glass material of claim 18 having the following formula:

Formula IV



Where R = Alkyl (C_1 - C_6), Phenyl, Substituted Phenyl
 R_1 = Alkyl, Phenyl
 R_2 = Alkyl, Phenyl
 X, U, Y = Si, Ge, Ti or Sn
 Z = ~~Alkyl, Substituted Alkyl, Phenyl, Substituted Phenyl~~

23-25 (Canceled)

25-26. (Currently Amended) The non-aqueous sol-gel spin-on glass material of claim 17 18, further comprising a UV light blocking material and/or an oxygen scavenger.

26-27. (Currently Amended) The non-aqueous sol-gel spin-on glass material of claim 17 18, further comprising a light-scattering material.

~~27.~~ 28. (Withdrawn-currently amended) A process for patterning the non-aqueous sol-gel spin-on glass material of claim 17 comprising: a) coating a substrate with said material followed by soft baking at 110°C (1hr), 120°C (1-2 hr); b) exposing the coated substrate of step a) to UV illumination in a desired pattern; c) post-exposure baking the coated substrate of step b) at a temperature from 100°C to 120°C for 30 to 60 minutes; d) cooling the coated substrate of step c) to room temperature; e) removing the non-exposed areas of the coating on the coated substrate of step d); f) drying the coated substrate of step e); g) hard baking the coated substrate of step f) at a temperature from 120 °C and 150 °C for 1 to 3 hours.

~~28.~~ 29. (Withdrawn-currently amended) The process of claim ~~27~~ 28, wherein the non-exposed areas of the coating on the coated substrate are removed by developing in a suitable organic solvent.

~~29.~~ 30. (Withdrawn-currently amended) The process of claim ~~28~~ 29, wherein in step e) the organic solvent is tetrahydrofuran, methylethylketone, acetone, n-propylacetate, or mixture of these solvents.

~~30.~~ 31. (Withdrawn-currently amended) The process of claim ~~27~~ 28, wherein in step f) the coated substrate is dried by flushing with a non-reactive gas.

~~31.~~ 32. (Withdrawn-currently amended) The process of claim ~~27~~ 28, wherein in step a) the substrate is glass, quartz, sapphire, silicon, a metalized substrate or a polymeric film.

~~32.~~ 33. (Withdrawn-currently amended) The process of claim ~~27~~ 28, wherein in step a) the coating is carried out by spin coating, dip coating, spray coating or doctor blade coating.

34. (New) The non-aqueous sol-gel spin-on glass material of claim 18, wherein the phosphor dopant comprises YAG base phosphor or moisture sensitive phosphor nano-particles.

35. (New) A process for producing the non-aqueous sol-gel spin-on glass material of claim 18, the process comprising reacting an alkyl substituted trialkoxysilane or dialkyl substituted dialkoxysilane with a silane diol, wherein said alkyl group has from 1 to 8 carbon atoms, wherein the reaction of the alkyl substituted trialkoxysilane or dialkyl substituted dialkoxysilane silane with the silane diol is carried out in a non-aqueous medium in the presence of a catalyst, the process further comprising adding to said sol-gel spin-on glass material a phosphor dopant, which comprises YAG base phosphor or moisture sensitive phosphor nano-particles or an organic material selected from organic dyes or metal complexes.

36. (New) The process of claim 35, wherein the phosphor dopant comprises YAG base phosphor or moisture sensitive phosphor nano-particles.